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In re Patent Application of:

: Docket: YOR919990336US2

Chao-kun Hu et al.

: Prior Group Art Unit: 2815

Serial No.: To be Assigned

: Prior Examiner: A. Wilson

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Date: November 13, 2001

For: REDUCED ELECTROMIGRATION AND STRESSED INDUCED MIGRATION OF Cu WIRES BY SURFACE COATING

INFORMATION DISCLOSURE STATEMENT PURSUANT TO 37 C.F.R. §1.98(d)



Commissioner for Patents Washington, D.C. 20231

Sir:

Fax No.:

Pursuant to applicants' duty of disclosure under 37 C.F.R. §1.56 and consistent with 37 C.F.R. §§1.97 and 1.98, submitted herewith is a Form PTO-1449 listing references that may be material to the above-captioned application.

The listed references were previously cited by or submitted to the Patent and Trademark Office in prior parent application, U.S. Serial No. 09/361,573, filed July 27, 1999, reliance upon which for an earlier effective filing date is claimed under 35 U.S.C. §120. Accordingly, pursuant to 37 C.F.R. §1.98(d) copies of said references are not enclosed herewith.

This information Disclosure Statement is being submitted concurrently at filing, thus no fee or certification under 37 C.F.R. §1.97 is required.

Respectfully submitted, Attorney for the Applicant(s)

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